REVISED SPECIFICATIONS AS ON 27 DECEMBER 2023

<u>Electrochemical Workstation/integrated Bi-PotentiostatSystemwith EIS and RDE/RRDE system</u> Specifications

Integrated Bi- Potentiostat Electrochemical system Specifications:

General Techniques

- Cyclic Voltammetry (CV)
- Linear Sweep Voltammetry (LSV) with stripping
- Bulk Electrolysis with Coulometry (BE)

Trace Metal analysis & Pulse Techniques

- Differential Pulse Voltammetry (DPV) with stripping
- Normal Pulse Voltammetry (NPV) with stripping
- Square Wave-Osteryoung Voltammetry with stripping

Corrosion

• Tafel Plot (TAFEL), potentiodynamic deactivation, pitting corrosion, corrosion rate, linear Polarization, Corrosion current etc.

Fuel cell

- Multi-Potential Steps
- Multi-Current Steps
- Chronopotentiometry
- Polarisation I-V curves Linear Sweep
- Open Circuit Potential Time (OCPT)

Impedance

- AC Impedance (IMP)
- Mott-Schottky
- Impedance Potential (IMPE)
- Impedance Simulator with fitting
- Open Circuit Potential Time (OCPT)

Battery Charge/Discharge

 Galvanostatic Charge discharge single/multiple cycle -Chrono Potentiometry (CP) with potential limits, polarity by potential or time, no. of cycles etc

Deposition Studies

• Single or Multi potential steps with charge limits, single or multi current steps, mixed voltage/current control using advanced programming.

General Useful Techniques

- Chrono Amperometry (CA)
- AC Voltammetry (ACV) with stripping with an external / internal signal generator.
- Hydrodynamic Modulation Voltammetry
- Chronopotentiometry with Current Ramp
- RDE control (0-10V output)
- IR Compensation
- External Potential Input

Hardware Specification:

- Integrated Bi-Potentiostat / Galvanostat:2- or 3- 4 electrode configuration
- Maximum potential: ±15VMaximum current: 1Amp
- Compliance Voltage: >±17V
- Potentiostat rise time: 0.8µs typical
- Measured current range: ±20pA to ±1A in 8 ranges or above.
- Measured current resolution: 0.003% of the current range
- Applied current accuracy:±0.2% of setting, ±0.05% of range
- Input bias current: < 20 pA,
- CV and LSV scan rate: $10 \mu V/s 75 V/s$ two channels simultaneously.
- Potential Increment during scan: ≤ 0.1mV
- CA and CC pulse width: 0.00016 1000 sec
- CA and CC minimum sample interval: ≤80 μs

- DPV and NPV pulse width: 0.001 to 10 Sec
- i-t sample interval: minimum 80 µs, both channels
- IMP frequency: 10µHz to 1MHz
- IMP amplitude: 1 mV 200 mV peak
- Fast data acquisition: dual channel 16-bit ADC, ≥ 125000 samples/sec simultaneously
- Automatic and manual iR compensation
- USB port for data communication

Software Features: Windows based software for data processing.

- a) Graphic Display
- b) Present data plot, overlay plots: several sets of data overlaid for comparison, add data to overlay, adding data files to overlay plot etc.
- c) Should provide Single window experiment control, data organizing and analysis (including EIS circuit fitting) software.
- d) Should be Free upgradation for a lifetime.

RDE / Rotating ring disk electrode system

Required specifications are as follows:

- •System should be of compact design and easy to operate
- •It should have provision for conducting electrochemical experiments both in RDE and RRDE mode
- •Remote and Manual controlled rotation should be possible
- •It should allow remote control from the PC (rotational speed ON/OFF)
- •Rotational speed range 10-8000 rpm,
- •Speed should be displayed in a display unit
- •Start/Stop (external): should have provision for digital motor stop input signal on external I/O port as optional. Available TTL logic: active high or active low, jumper selectable. The front panel LED should indicate when external motor stop is active.
- •Enclosure Interlock: should be capable of preventing rotation when enclosure window is in raised position. Front panel LED should indicate enclosure interlock state.

Specifications

Rotational range: 10to 8,000 rpm

Rotator shaft: The rotating shaft should be fabricated from PEEK and stainless steel.

Operating temperature: 10 to 50 deg C

Relative humidity: ≤ 80% Motor Power: 11 W

Motor Type: Permanent magnet

Max. Continuous Torque: 18.7 milliNewton-meters

Motor Protection: Motor current should be electronically limited.

RDE/RRDE shaft:The rotating shaft should be fabricated from PEEK and stainless steel. It should be compatible with Fixed/Change Disk RDE/RRDE Tip of 5.0 mm disk OD, 15.0 mm OD PTFE shroud.

The shaft should also be compatible with High Collection Efficiency (43.9%) RRDE Tip. Should have provision for using gas-purged bearing assembly for the shaft.

Electrode connections Brush: Electrode connections to the rotating shaft should be made using silver-carbon brushes.

OEM for electrode rotator and RDE/RRDE tip must be same.

Accessories for RDE/RRDE system

- a) RDE/RRDE Cell with Water Jacket: Should be 150ml volume with 4×14/20 ports and 1×24/25 central port including PTFE Stopper for each port. Dual Port Gas Inlet and Single Port Gas Outlet Accessories canmount in any 14/20 side port.
- **b)** Glassy Carbon Disk, Platinum Ring Fixed Disk RRDE Tip: Disk OD = 5.5 mm, Ring OD = 8.5 mm, Ring ID = 6.5 mm, PTFE ring-disk separator, 15.0 mm OD PEEK shroud should be provided.
- **c) Standard Platinum Counter Electrode Kit:** Should include isolation tube and adapter to fit 14/20 port with, Pt Wire OD: 0.5 mm, Pt Wire Approximate Surface Area: 4.7 cm2 and Epoxy Shroud Dimensions: 6.9 mm OD x 150 mm Long.
- **d)** Single Junction Silver Chloride (Ag/AgCl) Reference Electrode: Standard Potential: 0.199 V vs. NHE, Filling Solution: 4 M KCl with AgCl. Should include 14/20 PTFE adapter and storage bottle of filling solution.
- e) Hg/HgO Reference electrode

f) Polishing Kit: This kit should include, 2 polishing bases, 6 artificial fleece polishing cloths, 5 polishing cloths, 5 sheets of 2000# sandpaper, 5 sheets of 3000# sandpaper, 20 grams of 1.5um polishing powder, 20 grams of 0.5um polishing powder, 20 grams of 0.05um polishing powder.

Warranty: 1 Year warranty

Computer: Desktop/Laptop Computer i5 Processor, 8GB DDR4 RAM, 512 GB-SSD/1 TB HDD

Training: Training should be provided to the students & staff who will be operating the system.